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|---|--|---|-------------------------|
| | Application No. | Applicant(s) | |
| | 10/808,354 | TANAKA ET ^I AL. | |
| Notice of Allowability | Examiner | Art Unit | |
| | Toan Ton | 2871 | |
| The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313 | ears on the cover sheet with the co (OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to | orrespondence addresolication. If not included will be mailed in due co | d ourse. THIS |
| 1. This communication is responsive to papers filed 07/07/05. | | • | |
| 2. The allowed claim(s) is/are <u>1-6</u> . | | : | |
| 3. | | | |
| Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material | 5. ☐ Notice of Informal Pa 6. ☐ Interview Summary Paper No./Mail Dat 8), 7. ☑ Examiner's Amendr 8. ☐ Examiner's Stateme 9. ☐ Other | (PTO-413), e nent/Comment | · |

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REASONS FOR ALLOWANCE

1. Claims 1-6 are allowed.

The following is an examiner's statement of reasons for allowance: the prior art of record does not anticipate nor render obvious to one ordinary skilled in the art a method of manufacturing liquid crystal display device comprising a combination of various steps as claimed, more specifically, a direction in the second slant vacuum deposition step having azimuth angle different from at least an azimuth angle of the first slant vacuum deposition step so as to form a second inorganic slant vacuum deposition layer near the gap section and on the first inorganic slant vacuum deposition layer, wherein the direction for disposing the inorganic material unidirectionally in the first or the second slant vacuum deposition step is along a longitudinal direction of the gap section.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

CONTACT INFORMATION

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toan Ton whose telephone number is (571) 272-2303.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

September 2, 2005

TOANTON PRIMARY EXAMINER